

L Number	Hits	Search Text	DB	Time stamp
1	3	electrophotic same (semiconductor or photovoltaic)	USPAT; US-PGPUB; DERWENT	2003/11/19 10:33
2	3	electrophotic and (semiconductor or photovoltaic)	USPAT; US-PGPUB; DERWENT	2003/11/19 10:33
3	10	electrophotic	USPAT; US-PGPUB; DERWENT	2003/11/19 10:33
4	405	(mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))	USPAT; US-PGPUB; DERWENT	2003/11/19 11:23
5	34	(mask and electrostatic) and (electrospray\$3 same (substrate or support or surface))	USPAT; US-PGPUB; DERWENT	2003/11/19 10:40
6	22	((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and mask near5 (aperture or hole or distance)	USPAT; US-PGPUB; DERWENT	2003/11/19 11:23
7	245	((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and (mask or electrostatic) same (substrate or support or surface)	USPAT; US-PGPUB; DERWENT	2003/11/19 11:24
8	17	((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and (mask and electrostatic) same (substrate or support or surface)	USPAT; US-PGPUB; DERWENT	2003/11/19 11:24
10	8	((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and mask near5 (aperture or hole or distance) and ((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and (mask and electrostatic) same (substrate or support or surface))	USPAT; US-PGPUB; DERWENT	2003/11/19 11:25
11	31	((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and mask near5 (aperture or hole or distance) or ((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and (mask and electrostatic) same (substrate or support or surface))	USPAT; US-PGPUB; DERWENT	2003/11/19 11:25
12	23	((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and mask near5 (aperture or hole or distance) or ((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and (mask and electrostatic) same (substrate or support or surface)) not ((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and mask near5 (aperture or hole or distance) and ((mask or electrostatic) and (electrospray\$3 same (substrate or support or surface))) and (mask and electrostatic) same (substrate or support or surface))	USPAT; US-PGPUB; DERWENT	2003/11/19 11:25